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# Standard Practice for Microetching Metals and Alloys<sup>1</sup>

This standard is issued under the fixed designation E407; the number immediately following the designation indicates the year of original adoption or, in the case of revision, the year of last revision. A number in parentheses indicates the year of last reapproval. A superscript epsilon  $(\varepsilon)$  indicates an editorial change since the last revision or reapproval.

This standard has been approved for use by agencies of the U.S. Department of Defense.

ε<sup>1</sup> NOTE—Originally approved date was editorially corrected to 1970 in footnote 1 in January 2016.

#### 1. Scope

- 1.1 This practice covers chemical solutions and procedures to be used in etching metals and alloys for microscopic examination. Safety precautions and miscellaneous information are also included.
- 1.2 This standard does not purport to address all of the safety concerns, if any, associated with its use. It is the responsibility of the user of this standard to establish appropriate safety and health practices and determine the applicability of regulatory limitations prior to use. For specific cautionary statements, see 6.1 and Table 2.

#### 2. Referenced Documents

- 2.1 ASTM Standards:<sup>2</sup>
- D1193 Specification for Reagent Water
- E7 Terminology Relating to Metallography
- E2014 Guide on Metallographic Laboratory Safety

#### 3. Terminology

- 3.1 Definitions:
- 3.1.1 For definition of terms used in this standard, see Terminology E7.
  - 3.2 Definitions of Terms Specific to This Standard:
- 3.2.1 *tint etch*—an immersion etchant that produces color contrast, often selective to a particular constituent in the microstructure, due to a thin oxide, sulfide, molybdate, chromate or elemental selenium film on the polished surface that reveals the structure due to variations in light interference effects as a function of the film thickness (also called a "stain etch").

3.2.2 vapor-deposition interference layer method— a technique for producing enhanced contrast between microstructural constituents, usually in color, by thin films formed by vacuum deposition of a dielectric compound (such as ZnTe, ZnSe, TiO<sub>2</sub>, ZnS or ZnO) with a known index of refraction, generally due to light interference effects (also known as the "Pepperhoff method").

#### 4. Summary of Practice

- 4.1 Table 1 is an alphabetical listing of the metals (including rare earths) and their alloys for which etching information is available. For each metal and alloy, one or more etchant numbers and their corresponding use is indicated. Alloys are listed as a group or series when one or more etchants are common to the group or series. Specific alloys are listed only when necessary. When more than one etchant number is given for a particular use, they are usually given in order of preference. The numbers of electrolytic etchants are *italicized* to differentiate them from nonelectrolytic etchants.
- 4.2 Table 2 is a numerical listing of all the etchants referenced in Table 1 and includes the composition and general procedure to be followed for each etchant.
- 4.3 To use the tables, look up the metal or alloy of interest in Table 1 and note the etchant numbers corresponding to the results desired. The etchant composition and procedure is then located in Table 2corresponding to the etchant number.
- 4.4 If the common name of an etchant is known (Marble's, Vilella's, etc.), and it is desired to know the composition, Table 3contains an alphabetical listing of etchant names, each coded with a number corresponding to the etchant composition given in Table 2.

#### 5. Significance and Use

5.1 This practice lists recommended methods and solutions for the etching of specimens for metallographic examination. Solutions are listed to highlight phases present in most major alloy systems.

#### 6. Safety Precautions

6.1 Before using or mixing any chemicals, all product labels and pertinent Material Safety Data Sheets (MSDS) should be

<sup>&</sup>lt;sup>1</sup> This practice is under the jurisdiction of ASTM Committee E04 on Metallography and is the direct responsibility of Subcommittee E04.01 on Specimen Preparation.

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<sup>&</sup>lt;sup>2</sup> For referenced ASTM standards, visit the ASTM website, www.astm.org, or contact ASTM Customer Service at service@astm.org. For *Annual Book of ASTM Standards* volume information, refer to the standard's Document Summary page on the ASTM website.

read and understood concerning all of the hazards and safety precautions to be observed. Users should be aware of the type of hazards involved in the use of all chemicals used, including those hazards that are immediate, long-term, visible, invisible, and with or without odors. See Guide E2014 on Metallographic Laboratory Safety for additional information on; Chemical Safety, Electrolytic Polishing/Etching and Laboratory Ventilation/Fume Hoods.

- 6.1.1 Consult the product labels and MSDSs for recommendations concerning proper protective clothing.
- 6.1.2 All chemicals are potentially dangerous. All persons using any etchants should be thoroughly familiar with all of the chemicals involved and the proper procedure for handling, mixing, and disposing of each chemical, as well as any combinations of those chemicals. This includes being familiar with the federal, state, and local regulations governing the handling, storage, and disposal of these chemical etchants.
- 6.2 Some basic suggestions for the handling and disposing of etchants and their ingredients are as follows:
- 6.2.1 When pouring, mixing, or etching, always use the proper protective equipment, (glasses, gloves, apron, etc.) and it is strongly recommended to always work under a certified and tested fume hood. This is imperative with etchants that give off noxious odors or toxic vapors that may accumulate or become explosive. In particular, note that solutions containing perchloric acid must be used in an exclusive hood equipped with a wash down feature to avoid accumulation of explosive perchlorates. See Guide E2014 on Metallographic Laboratory Safety for additional information on safety precautions for electrolytes containing perchloric acid..
- 6.2.2 No single type of glove will protect against all possible hazards. Therefore, a glove must be carefully selected and used to ensure that it will provide the needed protection for the specific etchant being used. In some instances it may be necessary to wear more than one pair of gloves to provide proper protection. Information describing the appropriate glove may be obtained by consulting the MSDS for the chemical being used. If that does not provide enough detailed information, contact the chemical manufacturer directly. Additionally, one can contact the glove manufacturer or, if available, consult the manufacturers glove chart. If the chemical is not listed or if chemical mixtures are being used, contact the glove manufacturer for a recommendation.
- 6.2.3 Use proper devices (glass or plastic) for weighing, mixing, containing, and storage of solutions. A number of etchants generate fumes or vapors and should only be stored in properly vented containers. Storage of fuming etchants in sealed or non-vented containers may create an explosion hazard.
- 6.2.4 When mixing etchants, always add reagents to the solvent unless specific instructions indicate otherwise.
- 6.2.5 When etching, always avoid direct physical contact with the etchant and specimen; use devices such as tongs to hold the specimen (and tufts of cotton, if used).
- 6.2.6 Methanol is a cumulative poison hazard. Where ethanol or methanol, or both are listed as alternates, ethanol is the preferred solvent. Methanol should be used in a properly designed chemical fume hood.

- 6.2.7 When working with HF always be sure to wear the appropriate gloves, eye protection and apron. Buying HF at the lowest useable concentration will significantly reduce risk. Additionally, it is recommended that a calcium gluconate cream or other appropriate HF neutralizing agent be available for use if direct skin contact of the etchant occurs.
- 6.2.8 The EPA states that human studies have clearly established that inhaled chromium (VI) is a human carcinogen, resulting in an increased risk of lung cancer. Animal studies have shown chromium (VI) to cause lung tumors via inhalation exposure. Therefore, when working with Cr(VI) compounds such as  $K_2Cr_2O_7$  and  $CrO_3$  always use a certified and tested fume hood. Additional information can be obtained at the EPA website<sup>3</sup>.
- 6.2.9 For safety in transportation, picric acid is distributed by the manufacturer wet with greater than 30% water. Care must be taken to keep it moist because dry picric acid is shock sensitive and highly explosive especially when it is combined with metals such as copper, lead, zinc, and iron. It will also react with alkaline materials including plaster and concrete to form explosive compounds. It should be purchased in small quantities suitable for use in six to twelve months and checked periodically for lack of hydration. Distilled water may be added to maintain hydration, It must only be stored in plastic or glass bottles with nonmetallic lids. If dried particles are noted on or near the lid, submerge the bottle in water to re-hydrate them before opening. It is recommended that any bottle of picric acid that appears dry or is of unknown vintage not be opened and that proper emergency personnel be notified.
- 6.2.10 Wipe up or flush any and all spills, no matter how minute in nature.
- 6.2.11 Properly dispose of all solutions that are not identified by composition and concentration.
- 6.2.12 Store, handle and dispose of chemicals according to the manufacturer's recommendations. Observe printed cautions on reagent bottles.
- 6.2.13 Information pertaining to the toxicity, hazards, and working precautions of the chemicals, solvents, acids, bases, etc. being used (such as material safety data sheets, MSDS) should be available for rapid consultation. A selection of useful books on this subject is given in Refs. (1-11)<sup>4</sup>.
- 6.2.14 Facilities which routinely use chemical etchants should have an employee safety training program to insure the employees have the knowledge to properly handle chemical etchants.
- 6.2.15 When working with etchants always know where the nearest safety shower, eye-wash station, and emergency telephone are located.

#### 7. Miscellaneous Information

- 7.1 If you know the trade name of an alloy and need to know the composition to facilitate the use of Table 1, refer to a compilation such as Ref (12).
- 7.2 Reagent grade chemicals shall be used for all etchants. Unless otherwise indicated, it is intended that all reagents

<sup>3</sup> http://www.epa.gov/ttn/atw/hlthef/chromium.html

<sup>&</sup>lt;sup>4</sup> The **boldface** numbers in parentheses refer to the list of references at the end of this standard.

conform to specifications of the Committee on Analytical Reagents of the American Chemical Society where such specifications are available. Other grades, such as United States Pharmacopeia (USP), may be used, provided it is first ascertained that the reagent is of sufficiently high purity to permit its use without detrimental effect.

- 7.2.1 Unless otherwise indicated, references to water shall be understood to mean reagent water as defined by Type IV of specification D1193. Experience has shown that the quality of tap water varies significantly and can adversely affect some etchants.
- 7.3 Methanol is usually available only as absolute methanol. When using this alcohol it is imperative that approximately 5 volume % of water is added whenever an etchant composition calls for 95 % methanol. Some of these etchants will not work at all if water is not present.
- 7.4 For conversion of small liquid measurements, there are approximately 20 drops/mL.
- 7.5 Etching should be carried out on a freshly polished specimen.
- 7.6 Gentle agitation of the specimen or solution during immersion etching will result in a more uniform etch.
- 7.7 The etching times given are only suggested starting ranges and not absolute limits.
- 7.8 In electrolytic etching, d-c current is implied unless indicated otherwise.
- 7.9 A good economical source of d-c current for small scale electrolytic etching is the standard 6-V lantern battery.
- 7.10 In electrolytic etching, the specimen is the anode unless indicated otherwise.
- 7.11 Do not overlook the possibility of multiple etching with more than one solution in order to fully develop the structure of the specimen.
- 7.12 Microscope objectives can be ruined by exposure to hydrofluoric acid fumes from etchant residue inadvertently left on the specimen. This problem is very common when the specimen or mounting media contain porosity and when the mounting material (such as Bakelite) does not bond tightly to the specimen resulting in seepage along the edges of the specimen. In all cases, extreme care should be taken to remove all traces of the etchant by thorough washing and complete drying of the specimen before placing it on the microscope stage.

- 7.13 Tint etchants (13, 14-16) are always used by immersion, never by swabbing, as this would inhibit film formation. An extremely high quality polish is required as tint etchants will reveal remaining polishing damage even if it is not visible with bright field illumination. After polishing, the surface must be carefully cleaned. Use a polyethylene beaker to contain the etchant if it contains fluorine ions (for example, etchants containing ammonium bifluoride, NH<sub>4</sub> FHF). The specimen is placed in the solution using tongs, polished face up. Gently agitate the solution while observing the polished surface. After coloration begins, allow the solution to settle and remain motionless. Remove the specimen from the etchant when the surface is colored violet, rinse and dry. A light pre-etch with a general-purpose chemical etchant may lead to sharper delineation of the structure after tint etching.
- 7.14 Specimens should be carefully cleaned before use of a vapor-deposition interference film ("Pepperhoff") method (13, **14-17**). A light pre-etch, or a slight amount of polishing relief, may lead to sharper delination of the constituents after vapor deposition. The deposition is conducted inside a vacuum evaporator of the type used to prepare replicas for electron microscopy. One or several small lumps of a suitable dielectric compound with the desired index of refraction is heated under a vacuum until it evaporates. A vacuum level of 1.3 to 0.013 Pa  $(10^{-3} \text{ to } 10^{-5} \text{ mm Hg})$  is adequate and the polished surface should be about 10-15 cm beneath the device that holds the dielectric compound. Slowly evaporate the lumps and observe the surface of the specimen. It may be helpful to place the specimen on a small piece of white paper. As the film thickness increases, the surface (and the paper) will become colored with the color sequence changing in the order yellow, green, red, purple, violet, blue, silvery blue. Stop the evaporation when the color is purple to violet, although in some cases, thinner films with green or red colors have produced good results.
- 7.15 Metals Handbook (18) provides additional advice on etching solutions and techniques for various alloys.

#### 8. Precision and Bias

8.1 It is not possible to specify the precision or bias of this practice since quantitative measurements are not made.

### 9. Keywords

9.1 etch; etchant; interference method; metallography; metals; microetch; microscope; microstructure; Pepperhoff method; tint etch



# **TABLE 1 Etchants for Metals**

Note 1—It is strongly recommended to always mix and use etchants under a certified and tested fume hood.

Note 2—Electrolytic etchants are italicized.

	Metal	Etchants	Uses
Aluminum Basa:			
Aluminum Base:	Pure Al	1a, 2, 3	general structure
rule Al		4, 5	grain structure under polarized light
		1b	grain boundaries and slip lines
	1000 parios	10.2.2	general structure
1000 series		1a, 3, 2 4, 5	general structure grain structure under polarized light
		4, 3 6, 7	phase identifications
		0, 1	phase identifications
	2000 series	3, 2, 1a	general structure
		8a, 6, 7	phase identifications
	3000 series	3, 1a	general structure
	3000 361163	4, 5	grain structure under polarized light
		8a, 6, 7	phase identifications
			•
	4000 series	3, 1a	general structure
	5000 series	3, 1a, 2, 6, 8a	general structure
		<i>4</i> , 5	grain structure under polarized light
	6000 series	3, 1a, 2, 6, 8a, 222	general structure
		4, 5	grain structure under polarized light
		1a, 2, 7, 6, 8a	phase identifications
	7000 05::	0.4-0	age and almost .
	7000 series	iTeh S <sup>3, 1a, 2</sup> 3b, 6 ndards	general structure
		iden S <sub>3h 6</sub> notaros	grain structure under polarized light phase identifications
		55, 0	phase identifications
Beryllium Base:		https://stan.dards.iteh.	general structure via polarized light
		11tt ps.//starg, 10tal us.1tcll.	general structure via polarized light
	Be alloys	11	general structure
Chromium Base:		12, 13c Cument Previevger	neral structure
Cobalt Base:	Pure Co	14 15 16 17	general structure
Hard	-facing and tool metals	14, 15, 16, 17 ASTM 118, 19, 20 / (2015) e1	general structure general structure
	gh-temperature alloys	20, 18, 16, 21, 22b, 24, 25	gonoral structuro
ittps://stand	ards.iten.ai/cataio	og/standards/s1st/d8a2d0 <sub>19</sub> 1-3636-4346-9a39-0a	phase identification
Columbium Base	(see niobium base)		
Columbiani base	(see mobium base)		
Copper Base:	Dura Cu	00 07 00 00 00 014 00 00 045 05	ganaval atmostrus
	Pure Cu	26, 27, 28, 29, 30, 31d, 32, 33, 34b, 35, 36, 37, 38, 39, 40, 41, 42, <i>8b</i> , 210, 215	general structure
		43, 28	chemical polish and etch
		13, 23	
Cu-A	Al (aluminum bronze)	44, 31d, 34b, 35, 36, 37, 38, 39, 40,	general structure
	0 0	45, 215	
	Cu-Be Cu-Cr	46, 41, 45	general structure
	Cu-Cr Cu-Mn	41 41	general structure general structure
	Cu-Ni	34, 47, 48, 40, 49, 50	general structure
	Cu-Si	41	general structure
C	Cu-Sn (tin bronze)	51, 52	general structure
	A during the constitution	24	and a second of the second of
Admiralty metal Gilding metal		8b	general structure
	Cartridge brass		
	ree-cutting brass		
F	0	31d, 32, 33, 41, 42, 49	general structure
F	Nickel silver		
F		00 07 00 00 00 11 11	
F	Cu alloys	26, 27, 28, 29, 30, 44, 41, 31d, 32, 33, 34b, 35, 36, 37, 38, 30, 310, 315	general structure
F		34b, 35, 36, 37, 38, 39, 210, 215	
F		34b, 35, 36, 37, 38, 39, 210, 215 53, 43, 28, <i>49</i>	chemical polish and etch
F		34b, 35, 36, 37, 38, 39, 210, 215	
		34b, 35, 36, 37, 38, 39, 210, 215 53, 43, 28, <i>49</i> 42, <i>49</i> , 210	chemical polish and etch darkens beta in alpha-beta brass

	TABLE 1   Continued	
Metal	Etchants	Uses
Erbium Base:	55, 56	general structure
Gadolinium Base:	55, 56, 57	general structure
Germanium Base:	58, 59, 60	general structure
Gold Base:		
Pure Au	61, 62	general structure
Fule Au	63	chemical polish and etch
Au allovo		
Au alloys	64b, 62	general structure
>90 % noble metals	63 61	chemical polish and etch general structure
200 % Hobie Metals	01	general structure
<90 % noble metals	65	general structure
Hafnium base:	66, <i>67, 68, 69</i> , 70	general structure
	71	grain structure under polarized light
	72	chemical polish and etch
Holmium Base:	55, 56	general structure
Iridium Base:	73c	general structure
Iron Book		
<i>Iron Base:</i> Pure Fe	74a	grain boundaries
i die i e	75	substructure
	210	colors ferrite grains
		·
Fe + C	76, 74a, 77, 78, 79	general structure
and	74a, 77, 31a, 223	ferrite grain boundaries
Fe + <1C + <4 % additions	80, 81, 82	prior austenitic grain boundaries in martensitic and bainitic steels
	78, 222a	untempered martensite
	31b, 78	carbides and phosphides (matrix darkened, carbides
	I I CII S'E'A II U AI US	and phosphides remain bright)
	83	cementite attacked rapidly, sustenite less, ferrite and
		iron phosphide least
	ttps://stanadards.ite	overheating and burning
	85	stains carbides
	D 0 0 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	chemical polish-etch
	210, 211	colors ferrite
	213, 214	colors carbides
	216	colors lath martensite in low-carbon high-alloy grade:
	222b	for dual phase steels; reveals pearlite, darkens
		martensite and outlines austenite
tps://standards.iteh.ai/catalog/s	standards/sist/d8a2d56f-3c36-4346-9a39	-0ae2b2c56d73/astm-e407-072015e
Fe + 4-12 Cr	80, 87, 88, 89, 90, 91, 79, 210	
	86	general structure
	86	chemical polish-etch
Fe + 12-30 Cr + <6 Ni (400 Series)	86 80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226	chemical polish-etch
Fe + 12–30 Cr + <6 Ni (400 Series)	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226	chemical polish-etch general structure
Fe + 12-30 Cr + <6 Ni (400 Series)	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96, 97</i> , 98	chemical polish-etch  general structure  signs phase
Fe + 12-30 Cr + <6 Ni (400 Series)	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226	chemical polish-etch  general structure  signs phase  carbides
Fe + 12-30 Cr + <6 Ni (400 Series)	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96, 97</i> , 98 <i>31c</i>	chemical polish-etch  general structure  signs phase
Fe + 12–30 Cr + <6 Ni (400 Series)	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96, 97</i> , 98 <i>31c</i> 86	chemical polish-etch  general structure  signs phase  carbides  chemical polish-etch
	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96, 97</i> , 98 <i>31c</i> 86 219 220	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite
Fe + 12–20 Cr + 4–10 Ni + <7 %	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96</i> , <i>97</i> , 98 <i>31c</i> 86 219 220 80, <i>31c</i> , 89, 99, 100, 91	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled trans-	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96, 97</i> , 98 <i>31c</i> 86 219 220 80, <i>31c</i> , 89, 99, 100, 91 <i>31c</i>	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation harden-	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96, 97</i> , 98 <i>31c</i> 86 219 220 80, <i>31c</i> , 89, 99, 100, 91 <i>31c</i> 86	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled trans-	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96, 97</i> , 98 <i>31c</i> 86 219 220 80, <i>31c</i> , 89, 99, 100, 91 <i>31c</i>	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation harden-	80, 87, 88, 89, 34, 40, 92, <i>93</i> , 94, 95, 91, 226 <i>96, 97</i> , 98 <i>31c</i> 86 219 220 80, <i>31c</i> , 89, 99, 100, 91 <i>31c</i> 86	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220 80, 31c, 89, 99, 100, 91 31c 86 220	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides and sensitization
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides and sensitization stains sigma phase
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure darkens delta ferrite speneral structure carbides and sensitization stains sigma phase delineates sigma phase and
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104 86	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals chemical polish-etch
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104 86 219	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals chemical polish-etch grain boundary etch (no twins)
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104 86	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals chemical polish-etch
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104 86 219	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals chemical polish-etch grain boundary etch (no twins)
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10 Mn (200 series)	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104 86 219 220	chemical polish-etch  general structure  signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals chemical polish-etch grain boundary etch (no twins) darkens delta ferrite
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10 Mn (200 series)	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104 86 219 220  89, 25, 105, 106, 97, 212, 221	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals chemical polish-etch grain boundary etch (no twins) darkens delta ferrite  general structure
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10 Mn (200 series)	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104 86 219 220  89, 25, 105, 106, 97, 212, 221 107, 108, 213	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals chemical polish-etch grain boundary etch (no twins) darkens delta ferrite  general structure y' precipitate
Fe + 12–20 Cr + 4–10 Ni + <7 % other elements (controlled transformation, precipitation hardening, stainless maraging alloys)  Fe + 15–30 Cr + 6–40 Ni + <5 % other elements (300 Series)  and  Fe + 16–25 Cr + 3–6 Ni + 5–10 Mn (200 series)	80, 87, 88, 89, 34, 40, 92, 93, 94, 95, 91, 226 96, 97, 98 31c 86 219 220  80, 31c, 89, 99, 100, 91 31c 86 220  13b, 89, 87, 88, 83a, 80, 94, 95, 91, 101, 212, 221, 226 13a, 102, 31c, 48c, 213 48, 96, 97, 98 103, 104, 98 103, 104 86 219 220  89, 25, 105, 106, 97, 212, 221 107, 108, 213 86	chemical polish-etch  general structure signs phase carbides chemical polish-etch grain boundary etch darkens delta ferrite  general structure carbides chemical polish-etch darkens delta ferrite  general structure  carbides chemical polish-etch darkens delta ferrite  general structure  carbides and sensitization stains sigma phase delineates sigma phase and welds of dissimilar metals chemical polish-etch grain boundary etch (no twins) darkens delta ferrite  general structure γ' precipitate chemical polish-etch

	TABLE 1   Continued	
Metal	Etchants	Uses
Tool steels	74a, 80, 14	general structure
	110	grain boundaries in tempered tool steel
	210, 211	colors ferrite, lower alloy grades
	214, 214	colors cementite
	224, 225	carbides attacked and colored
Superalloys	86, 87, 94, 221, 226	general etch
ouporumoyo	111	general structure
	111	γ' depletion
		,
Lead Base:		
Pure Pb	57, 112	general structure
	113	for alternate polishing and etching
	110	for alternate peneraling and eterling
Pb + <2 Sb	114, 115, 57, 74b	general structure
	113	for alternate polishing and etching
Pb + >2 Sb	114, 57, 74b	general structure
15172 05	113	for alternate polishing and etching
Pb + Ca	112	general structure
I b + Oa	113	
Dh allava	116, 117b	for alternate polishing and etching
Pb alloys		general structure
Babbitt	74b	general structure
Magnagium D		
Magnesium Base:	110 110 74- 100 101 100	general -t
Pure Mg	118, 119, 74a, 120, 121, 122	general structure
	123	stain-free polish-etch
	440 74 404 400	
Mg-Mn	119, 74a, 124, 122	general structure
Mg-Al, Mg-Al-Zn (Al + Zn $<$ 5 %)	118, 119, 74a, 125, 124, <i>123</i> , 122	general structure
	120, 125, 126, 127	phase identification
	124, 126, 127	grain structure
Mg-Al, Mg-Al-Zn (Al + Zn $>$ 5 %)	118, 119, 74a, 125, 124, 121, 122	general structure
	120, 125, 126, 127	phase identification
Mg-Zn-Zr	118, 119, 74a, 1d, 128, 124, 126,	general structure
and	127, 121, 122 00 Q TA	
Mg-Zn-Th-Zr	11 05 0// Sta <sub>120, 121</sub> al usoltt	phase identification
Mg-Th-Zr	118, 119, 74a, 1d, 124, 127, 121, 122	general structure
and	Dagumant Duggia	g
Mg-Rare Earth-Zr	120, 121	phase identification
-		·
Molybdenum Base:	98c, 129, 130, <i>131</i>	general structure
As cast	132a	chemical polish prior to etching
https://standaNickel Base:ai/catalog/s		
Pure Ni and high Ni alloys	133, 134, 47, 135, 136, 25, 108, 31c	general structure
	137	grain boundary sulfidation
Ni-Ag	38, 138, 50, 139	general structure
Ni-Al	<i>50</i> , 140, 141, <i>142</i> , 89, 143	general structure
Ni-Cr	144, 50, <i>83, 134, 145</i> , 98, 146, 147, <i>13a</i>	general structure
Ni-Cu	38, 138, 50, 133, 140, 25, <i>134</i> , 47,	general structure
	48b, 94, 108, 34	5
Ni-Fe	<i>50</i> , 140, 141, <i>83, 134</i> , 148, 40, 107, 149	general structure
	74e, 25, 150	orientation pitting
Ni-Mn	74e	general structure
Ni-Mo	143	general structure
Ni-Ti	143, 151, 50, 133	general structure
Ni-Zn	152	general structure
	.02	gonoral ollastaro
Superalloys	94, 105, 138, 153, 12, 87, 89, 212, 226	general structure
Superanoyo	25, 94	grain size
	107, 111, <i>13a</i>	reveals microstructural inhomogeneity
	133	grain boundary sulfidation
	154	fine precipitation structure
	<i>19b</i> , 155, 156	differential matrix and nonmetallic staining
	22a	for passive alloys (for example, UNS Alloy N06625)
	157	specific for UNS Alloy N10004
	107	submicroscopic structure in aged super-alloys particu-
		larly for electron microscopy. Stains the matrix when $\gamma'$
		precipitates are present
	154	$\gamma'$ banding
	18	pre-etch activation for passive specimens
	213	colors carbide and γ'

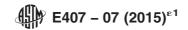
Palledium Base:		TABLE 1   Continued	
164, 120, 160   grain boundaries   1659   general structure   general structure   1659   general structure   1659   general structure   1659   general structure   general structure   1659   general structure	Metal	Etchants	Uses
Patentium Base:   165a   general structure   etch-polishing for viewing grains with polarized light	Niobium (Columbium) Base:		
Palladium Base:	Osmium Base:	165a	general structure
Pure Pid 81, 166, 62, 165a general structure 9 Pol alloys 166, 64 of, 216a general structure 9 central st		165a	etch-polishing for viewing grains with polarized ligh
Pol alloys		61 166 62 1652	general structure
Solition			=
### Platinum Base:     Pure Pt	•		=
Purp Pt			
P1 Alloys  64 bb, 73s  64 bb, 73s  65 chools metals  430 % noble metals  440 % noble metals  450 % noble m			
Pt Alloys	Pure Pt		=
167   electrolytic polish and etch	D. 411		
>90 % noble metals	Pt Alloys		
Solver   S		167	electrolytic polish and etch
Pi-to % Rh			
### Rhenium Base: 130, 98c, 132b, 170a general structure ### Rhodium Base: 73b general structure general structure general structure general structure general structure etch-polishing for viewing grains with polarized lig ### Silver Base: Pure Ag			=
## Rhenium Base:   136, 98c, 132b, 170a   general structure and general structure ge	Plutonium Base:	169	general structure
## Rodium Base: 73b general structure Ag Ag alolys			
### Ruthenium Base:    Fure Ag			•
Silver Base:   Pure Ag			
Pure Ag 172, 173, 62 general structure Ag-Qualloys Ag-Qualloys 130 general structure Ag-Qualloys 173 general structure Ag-Pot alloys 173 general structure general structure Ag-Pot alloys 173 general structure general structure Ag-Pot alloys 173, 176 general structure grain boundaries—retains carbide precipitate Thoulum Base:  Pure Th	ridiromani base.		etch-polishing for viewing grains with polarized lig
Ag alloys	Silver Base:		
Ag-Cu alloys Ag-Pd alloys Ag-pure Ta Tanalum Base: Pure Ta Ta alloys  Thorium Base: Pure Th Ta alloys  Thorium Base: Pure Th Thorium Base: Pure Sn  The Base: Pure Sn  The Base: Pure Sn  The Base: Pure Sn  The Base: ATM F4 185 Ag-Babitits Ag-Babi	Pure Ag	172, 173, 62	general structure
Ag-Cu alloys Ag-Pd alloys Ag-pure Ta Tanalum Base: Pure Ta Ta alloys  Thorium Base: Pure Th Ta alloys  Thorium Base: Pure Th Thorium Base: Pure Sn  The Base: Pure Sn  The Base: Pure Sn  The Base: Pure Sn  The Base: ATM F4 185 Ag-Babitits Ag-Babi	Ag alloys	65, 61, 174, 175, 62	general structure
Ag-Pd alloys         173         general structure           Ag solders         173, 176         general structure           Tantatum Base:         177         general structure           Pure Ta         159, 66, 178, 163, 161, 179         general structure           general structure         grain boundaries and inclusions           grain boundaries and inclusions         grain boundaries and inclusions           grain boundaries and inclusions         grain boundaries           Thorium Base:         Pure Th         general structure           Pure Sn         74d, 180, 151         general structure           Sn-Cd         74d         general structure           Sn-Fe         74d, 177a         general structure           Sn-Pb         182, 183, 74b         general structure           Sn-Pb         182, 183, 74b         general structure           Babbitis         183         general structure           Sn-Sb-Cu         74b         general structure           Titanium Base:         Pure Ti         186, 187, 67, 68, 69, 217         general structure           Fuel Ti         188         removes stain           Ti-6 Al-6 V-2 Sn         190         Stains alpha and transformed beta, retained beta mains white           Ti-6 III of the			
Ag solders		173	
Tanialum Base:   Pure Ta			<u> </u>
Pure Ta Ta alloys		nttps://stanuarus.itc	II.aij
Ta alloys  159, 66, 176, 163, 161, 179  164  164  168  Thorium Base: Pure Th ASTM E4185  Pure Sh Pure Sh Pure Sh Pure Sh Pure Sh Pure Sh Pure Th 181  Sn-Cd Sn-Fe Pure Th 182, 183, 74b 186  Sn-Pb 182, 183, 74b  Sn-Pb 182, 183, 74b  Sn-Pb 182, 183, 74b  Sn-Cd Sn-Cd Sn-Cd Sn-Fe Tifi Base: Pure Sh Sn-Pb 182, 183, 74b  Sn-Pb 182, 183, 74b  General structure	Pure Ta	177	general structure
164   grain boundaries and inclusions grain boundaries—retains carbide precipitate   Thorium Base:	Ta alloys	159, 66, 178, 163, 161, 179	
Pure Th	·	LOUGH TIEST THE TOTAL TO	
Pure Th	Thorium Base:		
Tin Base:         Pure Sn         74d, 180, 151         general structure           Sn-Cd         74d         general structure           Sn-Fe         74d, 177a         general structure           Sn-Fe         74d, 177a         general structure           Sn-Pb         182, 183, 74b         general structure           Sn-Coatings (on steel)         183         general structure           Babbitts         184         general structure           Sn-Sb-Cu         74b         general structure           Titanium Base:           Pure Ti         186, 187, 67, 68, 69, 217         general structure           Fure Ti         188         removes stain           Ti-5 Al-2,5 Sn         189         reveals hydrides           Ti-6 Al-6 V-2 Sn         190         Stains alpha and transformed beta, retained beta mains white           Ti-Al-Zr         191         general structure           Ti-8Mn         192         general structure           Ti-3 V-11 Cr-3 Al (aged)         192         general structure           Ti-Si         193         general structure           68, 69, 3a, 218         11, 1c         reveals alpha case           72, 192, 1778         chemical polish and etch		<u>ASTM E4<sub>185</sub>-07(2015)e1</u>	general structure
Pure Sn 74d, 180, 151 general structure grain boundaries Sn-Cd 74d general structure Sn-Fe 74d, 177a general structure Sn-Fe 182, 183, 74b general structure Sn-Pb 182, 183, 74b general structure Sn-Cd 16d derkens Pb in Sn-Pb eutectic Sn coatings (on steel) 183 general structure Babbitts 184 general structure Babbitts 184 general structure Babbitts 184 general structure Babbitts 184 general structure Fure Ti 186, 187, 67, 68, 69, 217 general structure Fure Ti 188 removes stain Fu-S Al-2,5 Sn 189 reweals hydrides Fi-6 Al-6 V-2 Sn 190 Stains alpha and transformed beta, retained beta mains white Fi-BMn 192 general structure Fi-BMn 192 general structure Fi-BMn 192 general structure Fi-10 general structure Fi-11 V-11 Cr-3 Al (aged) 192 general structure Fi-11 V-11 Cr-3 Al (aged) 192 general structure Fi-11 Individual 192 general structure Fi-12 Fi-13 V-11 Cr-3 Al (aged) 192 general structure Fi-14 V-11 Cr-3 Al (aged) 192 general structure Fi-15 Fi 190 general structure Fi-16 Fi 190 general structure Fi-17 V-11 Cr-3 Al (aged) 192 general structure Fi-18 Fi 190 general structure Fi-19 Fi 190 general structure Fi 190 general structure Fi 20 general structure Fi 21 general structure Fi 21 general structure Fi 22 general structure Fi 21 general structure Fi 22 general structure Fi 21 general structure Fi 22 general structure Fi 21 general structure Fi 22 general	tps://standardTh alloys ai/catal	og/standards/sist/d8a2d51851-3c36-4346-9a39	-0ae2b2c56d general structure 7-072015
181   grain boundaries   Sn-Cd   74d   general structure   Sn-Fe   74d, 177a   general structure   Sn-Pb   182, 183, 74b   general structure   Sn-Pb   182, 183, 74b   general structure   Sn-Pb   182, 183, 74b   general structure   Sn-Pb   183   general structure   Sn-Pb   Sn-Pb eutectic   Sn coatings (on steel)   183   general structure   Sn-Sb-Cu   74b   general structure   Sn-Sb-Cu   188   removes stain   Chemical polish and etch   removes stain   Chemical polish and etch   Stains alpha and transformed beta   reveals hydrides   Stains alpha and transformed beta   mains white   Stains   Stains alpha and transformed beta   Stains   Stain			
Sn-Cd	Pure Sn		
Sn-Fe Sn-Pb         74d, 177a general structure           Sn-Pb         182, 183, 74b general structure           Infe         darkens Pb in Sn-Pb eutectic           Sn coatings (on steel)         183 general structure           Babbitts         184 general structure           Sn-Sb-Cu         74b         general structure           Titanium Base:           Pure Ti         186, 187, 67, 68, 69, 217         general structure           Te Sh-2,5 Sn         189         removes stain           Ti-5 Al-2,5 Sn         189         ceveals hydrides           Ti-6 Al-6 V-2 Sn         190         Stains alpha and transformed beta, retained beta mains white           Ti-Al-Zr         191         general structure           Ti-BMn         192         general structure           Ti-3 V-11 Cr-3 Al (aged)         192         general structure           Ti-Si         193         general structure           Ti alloys         186, 187, 192, 194, 158, 132b, 1c, 67, general structure         general structure           68, 69, 3a, 218         11, 1c         reveals alpha case chemical polish and etch outlines and darkens hydrides in some alloys removes stain			=
Sn-Pb			<u> </u>
116   darkens Pb in Sn-Pb eutectic general structure Babbitts   183   general structure   184   general structure general structure   185   general structure   186   187, 67, 68, 69, 217   general structure removes stain   72   chemical polish and etch reveals hydrides   72   chemical polish and etch reveals hydrides   72   chemical polish and etch reveals hydrides   74   75   75   75   75   75   75   75			
Sn coatings (on steel)         183         general structure           Babbitts         184         general structure           Sn-Sb-Cu         74b         general structure           Titanium Base:           Pure Ti         186, 187, 67, 68, 69, 217         general structure           188         removes stain           Chemical polish and etch         reveals hydrides           Ti-5 Al-2,5 Sn         189         stains alpha and transformed beta, retained beta mains white           Ti-6 Al-6 V-2 Sn         190         Stains alpha and transformed beta, retained beta mains white           Ti-Al-Zr         191         general structure           Ti-8Mn         192         general structure           Ti-13 V-11 Cr-3 Al (aged)         192         general structure           Ti-Si         193         general structure           Ti-3loys         186, 187, 192, 194, 158, 132b, 1c, 67,         general structure           68, 69, 3a, 218         11, 1c         reveals alpha case           72, 192, 178         chemical polish and etch           170a         outlines and darkens hydrides in some alloys           188         removes stain	Sn-Pb		
Babbitts Sn-Sb-Cu 74b general structure general structure  Titanium Base:  Pure Ti 186, 187, 67, 68, 69, 217 general structure removes stain  Ti-5 Al-2,5 Sn 189 reveals hydrides  Ti-6 Al-6 V-2 Sn 190 Stains alpha and transformed beta, retained beta mains white  Ti-Al-Zr 191 general structure  Ti-8Mn 192 general structure  Ti-13 V-11 Cr-3 Al (aged) 192 general structure  Ti-Si 193 general structure  Ti-Si 194, 158, 132b, 1c, 67, general structure  68, 69, 3a, 218  11, 1c reveals alpha case  chemical polish and etch  rewoves stain			
Sn-Sb-Cu   74b   general structure			=
Titanium Base: Pure Ti 186, 187, 67, 68, 69, 217 general structure removes stain 72 chemical polish and etch reveals hydrides Ti-5 Al-2,5 Sn Ti-6 Al-6 V-2 Sn Ti-6 Al-6 V-2 Sn Ti-8 Mn Ti-3 V-11 Cr-3 Al (aged) Ti-Si Ti-Si Ti alloys Ti alloys Ti-Si Ti-S			
Pure Ti			g
Ti-5 Al-2,5 Sn Ti-6 Al-6 V-2 Sn Ti-6 Al-6 V-2 Sn Ti-8Mn Ti-13 V-11 Cr-3 Al (aged) Ti-8i Ti		186, 187, <i>67, 68, 69,</i> 217	general structure
Ti-5 Al-2,5 Sn Ti-6 Al-6 V-2 Sn Ti-6 Al-6 V-2 Sn Ti-8 Mn Ti-13 V-11 Cr-3 Al (aged) Ti-Si Ti alloys Ti alloys Ti-Si T			=
Ti-5 Al-2,5 Sn Ti-6 Al-6 V-2 Sn Ti-6 Al-6 V-2 Sn Ti-6 Al-6 V-2 Sn Ti-8 Ip0 Stains alpha and transformed beta, retained beta mains white general structure Ti-8Mn Ti-8Mn Ti-13 V-11 Cr-3 Al (aged) Ti-Si Ti alloys Ti alloys Ti alloys Ti-8, 192, 194, 158, 132b, 1c, 67, 68, 69, 3a, 218 11, 1c Treveals alpha case Treveals alpha case Chemical polish and etch outlines and darkens hydrides in some alloys removes stain			
Ti-6 Al-6 V-2 Sn  190 Stains alpha and transformed beta, retained beta mains white Ti-Al-Zr Ti-8Mn 192 general structure 192 general structure 193 Ti-13 V-11 Cr-3 Al (aged) Ti-Si 193 Ti alloys 186, 187, 192, 194, 158, 132b, 1c, 67, 68, 69, 3a, 218 11, 1c reveals alpha case 72, 192, 178 chemical polish and etch outlines and darkens hydrides in some alloys removes stain	Ti-5 Al-2.5 Sn		
Ti-Al-Zr       191       general structure         Ti-8Mn       192       general structure         Ti-13 V-11 Cr-3 Al (aged)       192       general structure         Ti-Si       193       general structure         Ti alloys       186, 187, 192, 194, 158, 132b, 1c, 67,       general structure         68, 69, 3a, 218       11, 1c       reveals alpha case         72, 192, 178       chemical polish and etch         170a       outlines and darkens hydrides in some alloys removes stain	· · · · · · · · · · · · · · · · · · ·		Stains alpha and transformed beta, retained beta
Ti-8Mn  192 general structure  Ti-13 V-11 Cr-3 Al (aged) 192 general structure gener	Ti-Al-Zr	191	
Ti-13 V-11 Cr-3 Al (aged)  Ti-Si  Ti alloys  192  general structure 68, 69, 3a, 218  11, 1c  reveals alpha case chemical polish and etch outlines and darkens hydrides in some alloys removes stain			S .
Ti-Si  Ti alloys  186, 187, 192, 194, 158, 132b, 1c, 67,  68, 69, 3a, 218  11, 1c  72, 192, 178  170a  188  189  193  general structure			<u> </u>
Ti alloys  186, 187, 192, 194, 158, 132b, 1c, 67,  68, 69, 3a, 218  11, 1c  72, 192, 178  170a  188  188  189  180  180  180  180  180			<u> </u>
11, 1c reveals alpha case 72, 192, 178 chemical polish and etch 170a outlines and darkens hydrides in some alloys 188 removes stain		186, 187, 192, 194, 158, 132b, 1c, 67,	•
72, 192, 178 chemical polish and etch 170a outlines and darkens hydrides in some alloys 188 removes stain			ravaals alnha casa
170a outlines and darkens hydrides in some alloys 188 removes stain			·
188 removes stain			
Tringeton Rose			
TUTUSIETI DASE.	Tungsten Base:		

	Titale : Communica	
Metal	Etchants	Uses
Pure W	98c, <i>131</i>	general structure
As cast	132a	chemical polish prior to etching
W-Th	209	general structure
Uranium Base:		
Pure U	67, <i>69</i> , <i>195</i> , <i>196</i>	general structure
U + Zr	68	general structure
U beryllides	170a	general structure
U alloys	67, 69, 195, 96	general structure
,	207	carbides
Vanadium Base:		
Pure V	170b, <i>165b</i>	general structure
	<i>197</i> , 198	grain boundaries
V alloys	199, 198	general structure
Zinc Base:		
Pure Zn	200a	general structure
Zn-Co	177	general structure
Zn-Cu	201	general structure
	203	distinguishes gamma ( $\gamma$ ) and epsilon ( $\epsilon$ )
Zn-Fe	74a	structure of galvanized sheet
Die castings	202	general structure
Zirconium Base:	66, <i>67</i> , 204, 68, 69, 205	general structure
	206	electrolytic polish and etch
	71	grain structure under polarized light
	72	chemical polish and etch

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<u>ASTM E407-07(2015)e1</u>

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# **TABLE 2 Numerical List of Etchants**

 $No{\text{\tiny TE}}\ 1\text{---It is strongly recommended to always mix and use etchants under a certified and test fume hood.}$ 

Etchant	Composition	Procedure
1	1 mL HF 200 mL water	<ul> <li>(a) Swab with cotton for 15 s.</li> <li>(b) Alternately immerse and polish several minutes.</li> <li>(c) Immerse 3–5 s.</li> <li>(d) Immerse 10–120 s.</li> </ul>
2	3 mL HF 100 mL water	(a) Swab 10 s to reveal general structure.  (b) Immerse 15 min, wash 10 min in water to form film with hatching which varies with grain orientation.
3	2 mL HF 3 mL HCI 5 mL HNO <sub>3</sub> 190 mL water	(a) Immerse 10–20 s Wash in stream of warm water. Reveals general structure.  (b) Dilute with 4 parts water-colors constituents—mix fresh.
4	24 mL H <sub>3</sub> PO <sub>4</sub>	Electrolytic: Use carbon cathode raising d-c voltage from 0–30 V in 30 s. Total etching time 3 min
	50 mL Carbitol (diethylene glycol monoethyl ether) 4 g boric acid 2 g oxalic acid 10 mL HF 32 mL water	
5	5 g HBF <sub>4</sub> 200 mL water	Electrolytic: Use Al, Pb, or stainless steel cathode. Anodize 1–3 min, 20–45 V d-c. At 30 V, etch for 1 min.
6	$25~\rm mL~HNO_3$ $75~\rm mL~water$	Immerse 40 s at 70°C (160°F). Rinse in cold water.
7	10–20 mL H <sub>2</sub> SO <sub>4</sub> 80 mL water	Immerse 30 s at 70°C (160°F). Rinse in cold water.
8	10 mL H <sub>3</sub> PO <sub>4</sub> 90 mL water	(a) Immerse 1–3 min at 50°C (120°F). (b) Electrolytic at 1–8 V for 5–10 s.
9	3–4 g sulfamic acid 5 drops HF 100 mL water	Use just prior to the last polishing operation. It is not intended as a final etchant. The specimen is examined as polished under polarized light.
10	10 mL HF 90 mL methanol (90 %)	Immerse 10–30 s.
ıttps://sta <mark>ll</mark> dards.i	teh.ai/catalog 2 mL HF ds/sist/d8a	12d56f-3c36-434 Immerse or swab few seconds to a minute. e407-072015e
12	$20~\rm mL~HNO_3$ $60~\rm mL~HCl$	Use a certified and tested hood. Do not store. Immerse or swab 5-60 s.
13	10 g oxalic acid 100 mL water	Electrolytic at 6 V:  (a) 10–15 s.  (b) 1 min.  (c) 2–3 s.
		Use stainless steel cathode and platinum or Nichrome connection to specimen.
14	10 mL HNO $_3$ 90 mL methanol (95 %)	Immerse few seconds to a minute.
15	15 mL HNO <sub>3</sub> 15 mL acetic acid 60 mL HCI 15 mL water	Use a certified and tested hood. Age before use. Immerse 5–30 s. May be used electrolytically.
16	5-10 mL HCI 100 mL water	Electrolytic at 3 V for 2–10 s.
17	5 mL HCI 10 g FeCl <sub>3</sub> 100 mL water	Electrolytic at 6 V for few seconds.
18	2–10 g CrO <sub>3</sub> 100 mL water	Use a certified and tested hood. Electrolytic at 3 V for 2-10 s.

	IA	BLE 2 Continued
Etchant	Composition	Procedure
19	A 8 g NaOH 100 mL water B	Immerse in freshly mixed Solutions A + B (1:1) for 5–10 s. If surface activation is necessary, first use Etch #18, then rinse in water. While still wet, immerse in Solutions A + B (1:1). Mixture of solutions A + B has 15-min useful life. Note: $KMnO_4$ is an agressive staining agent.
	Saturated aqueous solution of KMnO <sub>4</sub>	
20	$5~\mathrm{mL}~\mathrm{H_2}~\mathrm{O_2}~(30~\%) \\ 100~\mathrm{mL}~\mathrm{HCI}$	Use a certified and tested hood. Mix fresh. Immerse polished face up for few seconds.
21	1 g CrO <sub>3</sub> 140 mL HCl	Use a certified and tested hood. To mix, add the HCl to ${\rm CrO_3}$ . Electrolytic at 3 V for 2–10 s.
22	100 mL HCl 0.5 mL H <sub>2</sub> O <sub>2</sub> (30 %)	Use a certified and tested hood. Do not store. (a) Immerse or swab $\frac{1}{2}$ –3 min. Add H <sub>2</sub> O <sub>2</sub> dropwise to maintain action. (b) Electrolytic, 4 V, 3–5 s.
23	5 mL HCl	Electrolytic at 6 V for 10–20 s.
	95 mL ethanol (95 %) or methanol (95 %)	Hara a seekita da aad kaskad baada laasaa aa faaraa aada
24	5 mL HNO <sub>3</sub> 200 mL HCl 65 g FeCl <sub>3</sub>	Use a certified and tested hood. Immerse few seconds.
25	10 g CuSO <sub>4</sub> 50 mL HCl 50 mL water	Immerse or swab 5–60 s. Made more active by adding few drops of $\rm H_2~SO_4$ just before use.
26	5 g FeCl <sub>3</sub> 10 mL HCl 50 mL glycerol 30 mL water	Swab 16-60 s. Activity may be decreased by substituting glycerol for water.
27	1 g KOH 20 mL H <sub>2</sub> O <sub>2</sub> (3 %) 50 mL NH <sub>4</sub> OH 30 mL water	Dissolve KOH in water, then slowly add NH $_4$ OH to solution. Add 3 % H $_2$ O $_2$ last. Use fresh—immerse few seconds to a minute.
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28	1 g FeNO <sub>3</sub> 100 mL water	Swab or immerse few seconds to a minute.
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29	1 g $K_2$ $Cr_2$ $O_7$ 4 mL $H_2$ $SO_4$ 50 mL water	Use a certified and tested hood. Add 2 drops of HCl just before using. Swab few seconds to a minute.
https://standards.i	25 mL NH <sub>4</sub> OH 25 mL water 50 mL H <sub>2</sub> O <sub>2</sub> (3 %)	Mix NH <sub>4</sub> OH and water before adding H <sub>2</sub> O <sub>2</sub> . Must be used fresh. Swab 5–45 s. Se 1
31	10 g ammonium persulfate 100 mL water	<ul> <li>(a) Swab or immerse to 5 s.</li> <li>(b) Immerse to 2 min to darken matrix to reveal carbides and phosphides.</li> <li>(c) Electrolytic at 6 V for few seconds to a minute.</li> <li>(d) Immerse 3–60 s. Can be heated to increase activity.</li> </ul>
32	$60~{\rm g~CrO_3}$ 100 mL water	Use a certified and tested hood. Saturated solution. Immerse or swab 5–30 s.
33	10 g CrO <sub>3</sub>	Use a certified and tested hood. Add HCl just before use. Immerse 3–30 s. Phases can be colored by Nos. 35, 36, 37.
	2–4 drops HCl 100 mL water	
34	5 g FeCl <sub>3</sub> 50 mL HCl 100 mL water	(a) Immerse or swab few seconds to few minutes. Small additions of HNO <sub>3</sub> activate solution and minimize pitting.
		(b) Immerse or swab few seconds at a time. Repeat as necessary.
35	20 g FeCl <sub>3</sub> 5 mL HCl 1 g CrO <sub>3</sub> 100 mL water	Use a certified and tested hood. Immerse or swab few seconds at a time until desired results are obtained.
36	25 g FeCl <sub>3</sub> 25 mL HCl 100 mL water	Immerse or swab few seconds at a time until desired results are obtained.